

P22020.A01



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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : H FUJIMATSU et al.

Group Art Unit: Unknown

Appl. No. : 10/049,644

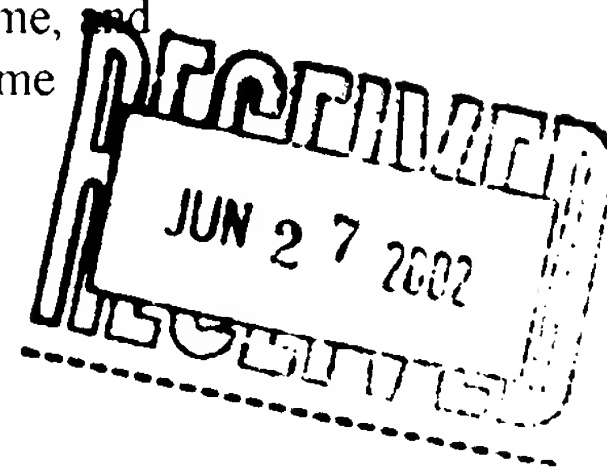
Examiner: Unknown

Filed : February 25, 2002

For : Battery Electrode Plate, Method for Manufacturing the Same, and
Nonaqueous-Electrolyte Rechargeable Battery Using the Same

INFORMATION DISCLOSURE STATEMENT

Commissioner of Patents and Trademarks
Washington, D.C. 20231



Sir:

Pursuant to 37 C.F.R. §1.97-§1.98 and 37 C.F.R. §1.56, Applicants call the attention of the Examiner to the following information.

Applicants direct the Examiner's attention to the following documents cited in International Application No. PCT/JP01/05536, and its International Search Report.

Japanese Laid-Open Publication No. 10-050348;

English translation of the abstract of Japanese Laid-Open Publication No. 10-050348;

Japanese Laid-Open Publication No. 10-334877;

English translation of the abstract of Japanese Laid-Open Publication No. 10-334877;

Japanese Laid-Open Publication No. 05-094812; and

English translation of the abstract of Japanese Laid-Open Publication No. 05-094812.

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Copies of the International Search Report in English was enclosed with the papers when entering the National Stage on February 25, 2002. The Examiner is invited to review these materials to see the relevance indicated during international examination with respect to the documents cited therein.

In addition, Applicants direct the Examiner's attention to the following documents:

U.S. Patent No. 5,460,904 to Gozdz et al as cited on line 13 of page 2 of the specification;

Japanese Laid-Open Publication No. 11-288741 as cited on line 26 of page 1 of the specification; and

English translation of the abstract of Japanese Laid-Open Publication No. 11-288741.

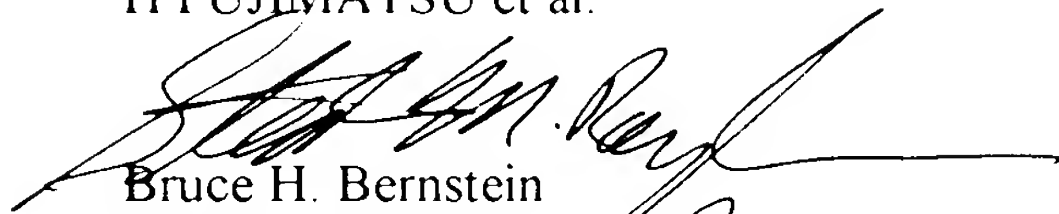
Copies of the above-noted documents are enclosed together a dully completed Form PTO-1449. The Examiner is requested to consider each of these documents, and to make them of record in this application by initialing in the appropriate spaces on the Form PTO-1449. Applicants respectfully request that the Examiner include a copy of the initialed Form PTO-1449 with the next communication from the U.S. Patent and Trademark Office.

Applicants note that an Office Action on the Merits has not been received in the instant application. However, if an Office Action on the Merits has issued, and is crossing this statement in the mail, the undersigned hereby authorizes the Commissioner to charge any fee necessary for the consideration of this statement, including any payment under 37 C.F.R. §1.17(p), to Applicant's Deposit Account No. 19-0089.

Should the Examiner have any questions or comments, the undersigned may be contacted
at the below listed telephone number.

Respectfully submitted.

H FUJIMATSU et al.



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| <p>Form PTO-1449</p> <p>U.S. Department of Commerce Patent and Trademark Office</p> | <p>Att. Docket No. , P22020</p> | <p>Serial No. 10/049,644</p> |
| <p>INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)</p> | <p>Applicant H. FUJIMATSU et al.</p> | |
| | <p>Filing Date February 25, 2002</p> | <p>Group Unknown</p> |

U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

[illegible]

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

| | | |
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| | 1 | English Translation of Abstract for JP Appl. No. 10-050348. |
| | 2 | English Translation of Abstract for JP Appl. No. 10-334877. |
| | 3 | English Translation of Abstract for JP Appl. No. 05-094812. |
| | 4 | English Translation of Abstract for JP Appl. No. 11-288741. |

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| EXAMINER | DATE CONSIDERED |
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*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.